

Supporting information

for

Single-crystalline Ni(OH)₂ nanosheets vertically aligned on three-dimensional nanoporous metal for high-performance asymmetric supercapacitors

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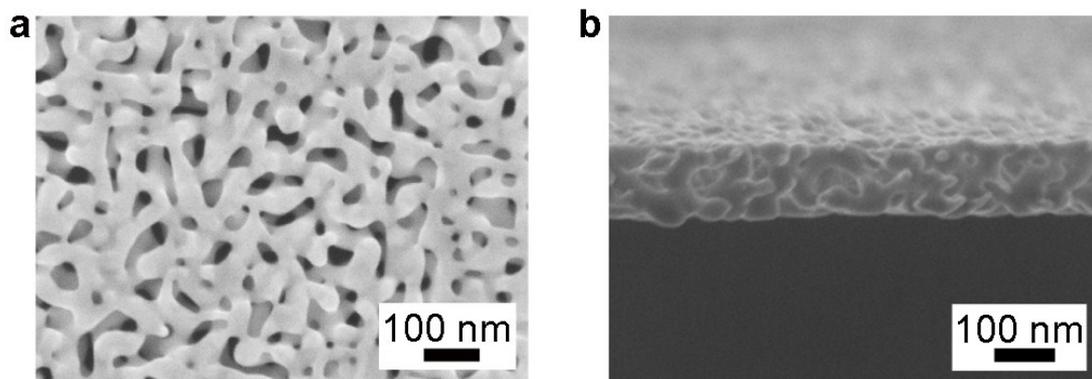


Figure S1. SEM images of **(a)** top view and **(b)** cross-sectional view of NP Au.

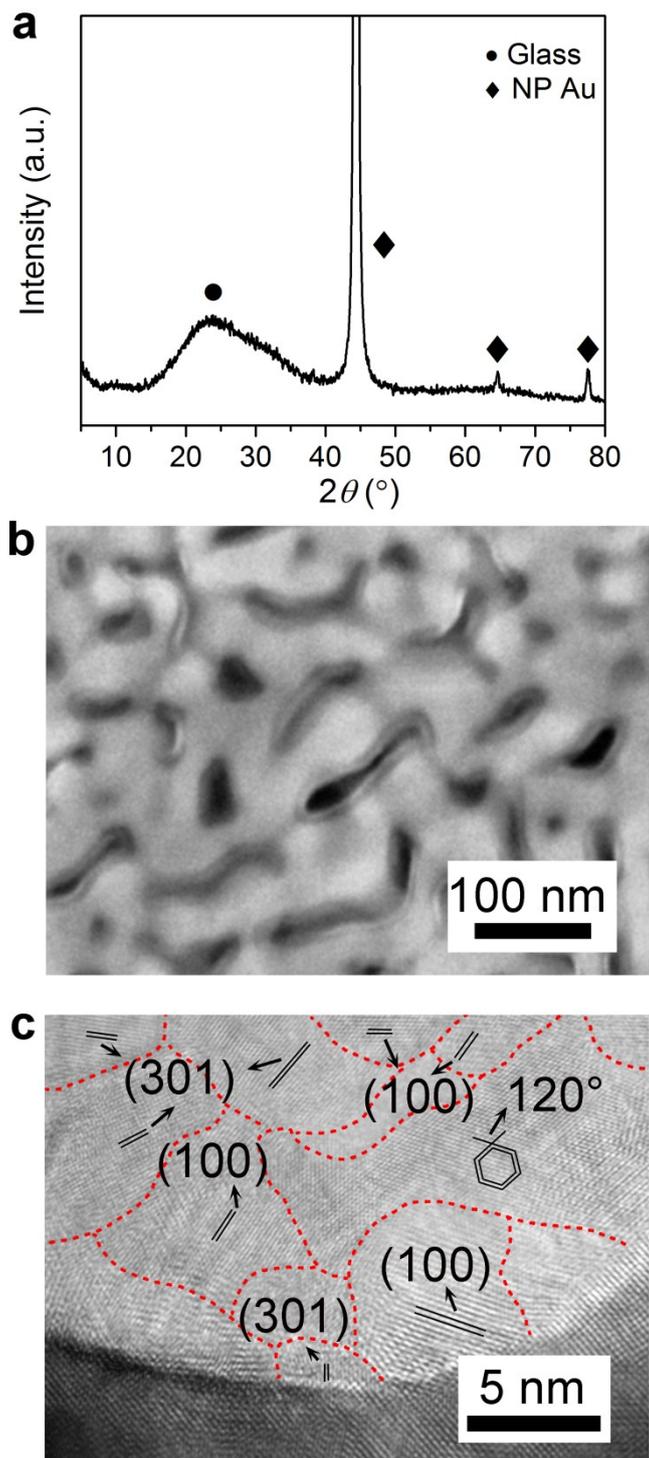


Figure S2. (a) XRD pattern (b) SEM and (c) HRTEM image of NP Au/RA Ni(OH)₂ electrode fabricated without the addition of K₂S₂O₈ in the aqueous solution.

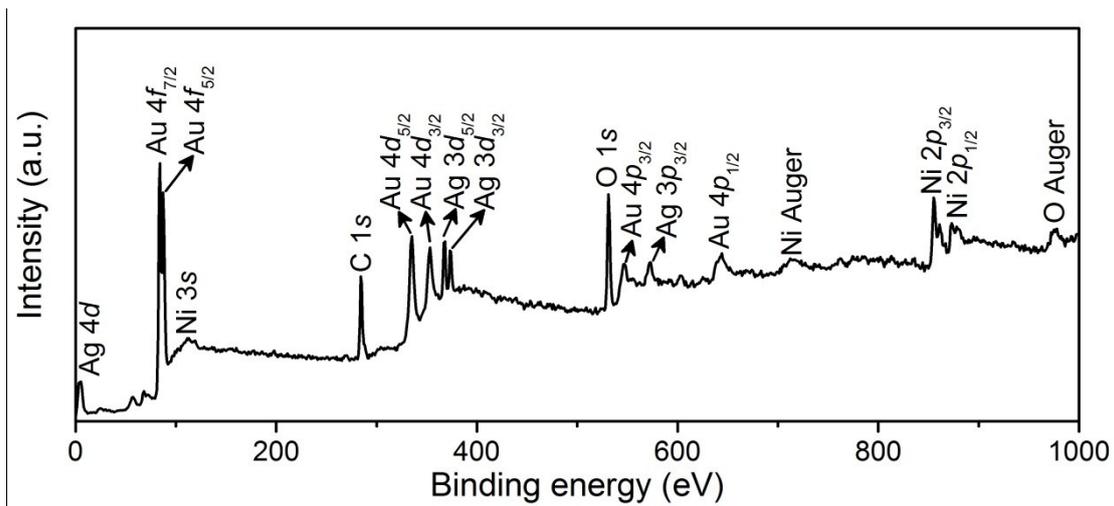


Figure S3. Typical XPS survey spectrum for the NP Au/VA Ni(OH)₂ electrode.

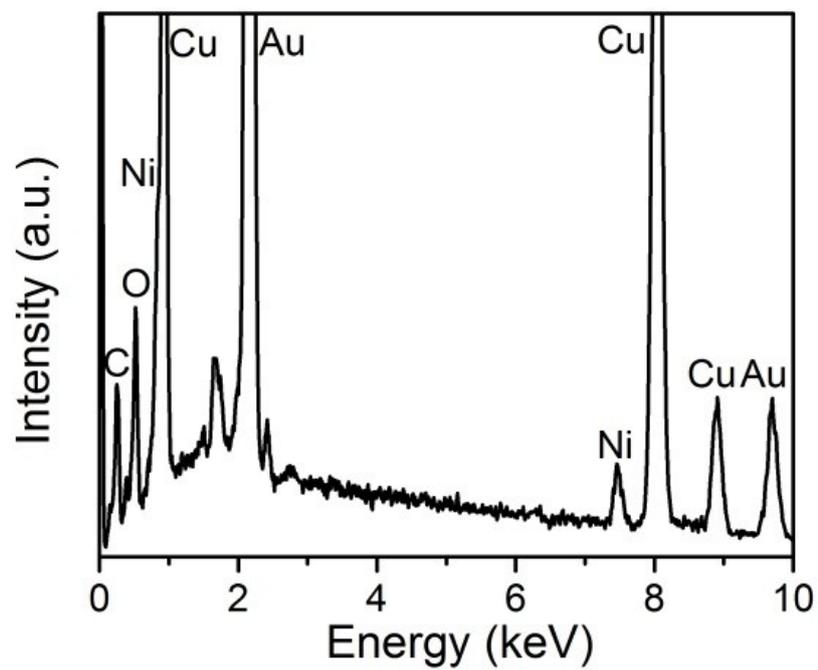


Figure S4. EDS spectrum of NP Au/VA Ni(OH)₂ electrode. The content Cu was from supported Cu foil.

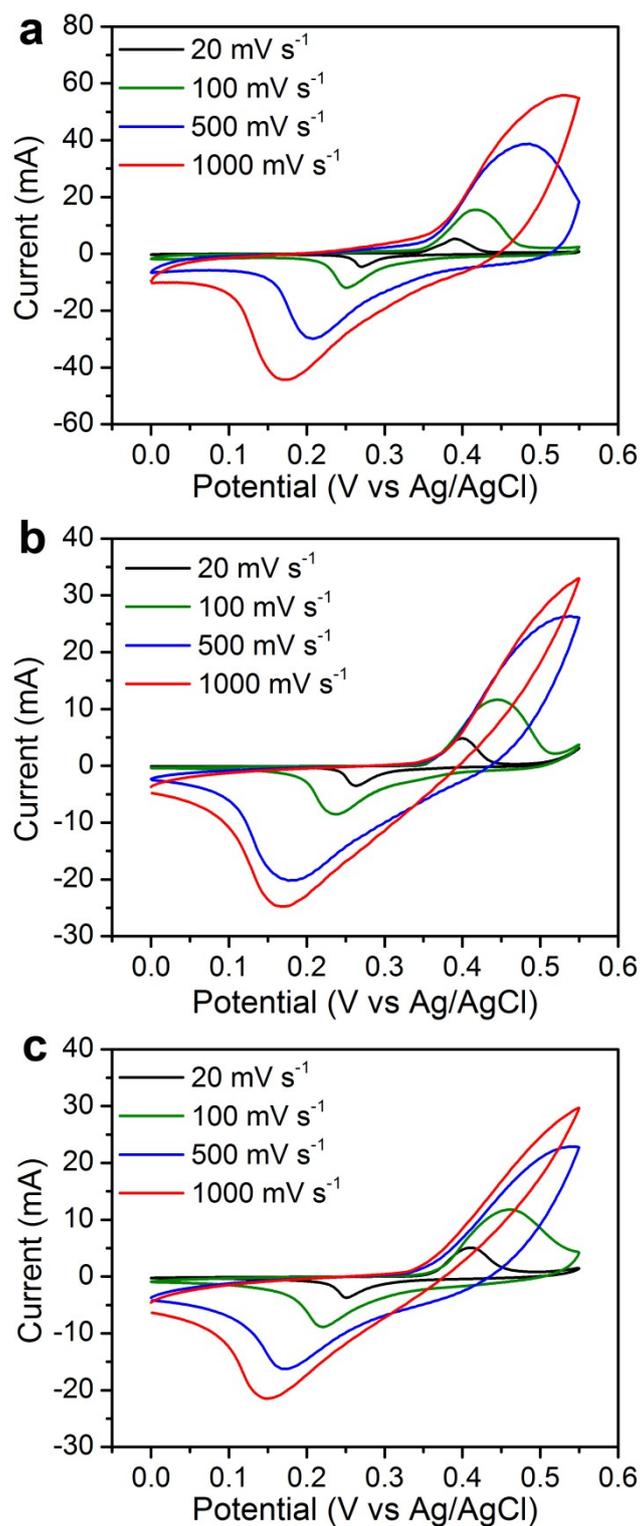


Figure S5. Typical CV curves of (a) NP Au/RA Ni(OH)₂, (b) CFP/VA Ni(OH)₂ and (c) CFP/RA Ni(OH)₂ electrodes at various scan rates.

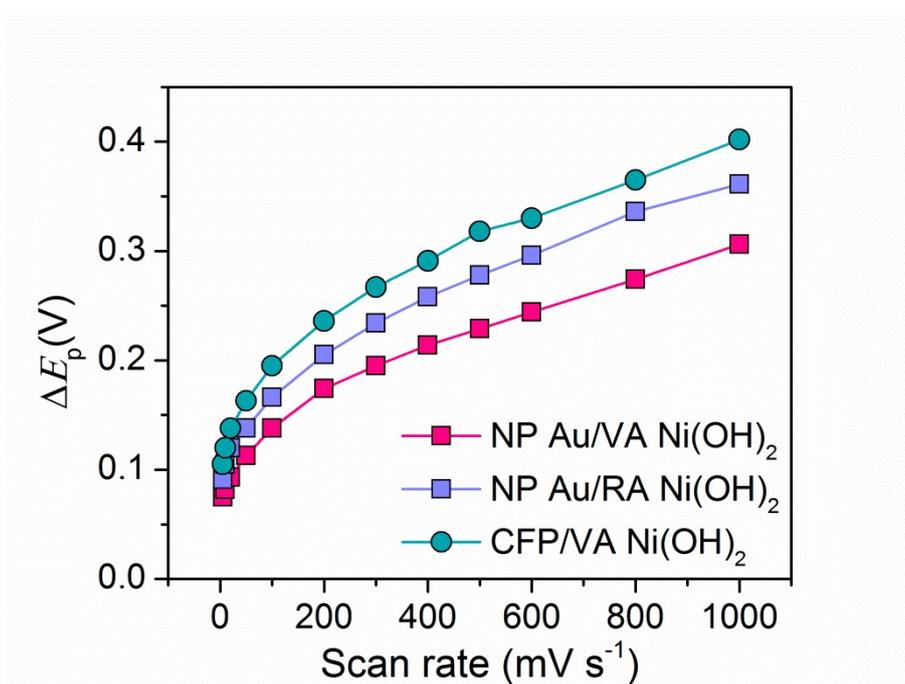


Figure S6. The potential difference between the anodic peaks and the cathode peaks ($\Delta E_p = E_O - E_R$) for NP Au/VA Ni(OH)₂, NP Au/RA Ni(OH)₂ and CFP/VA Ni(OH)₂ electrodes as a function of scan rate.

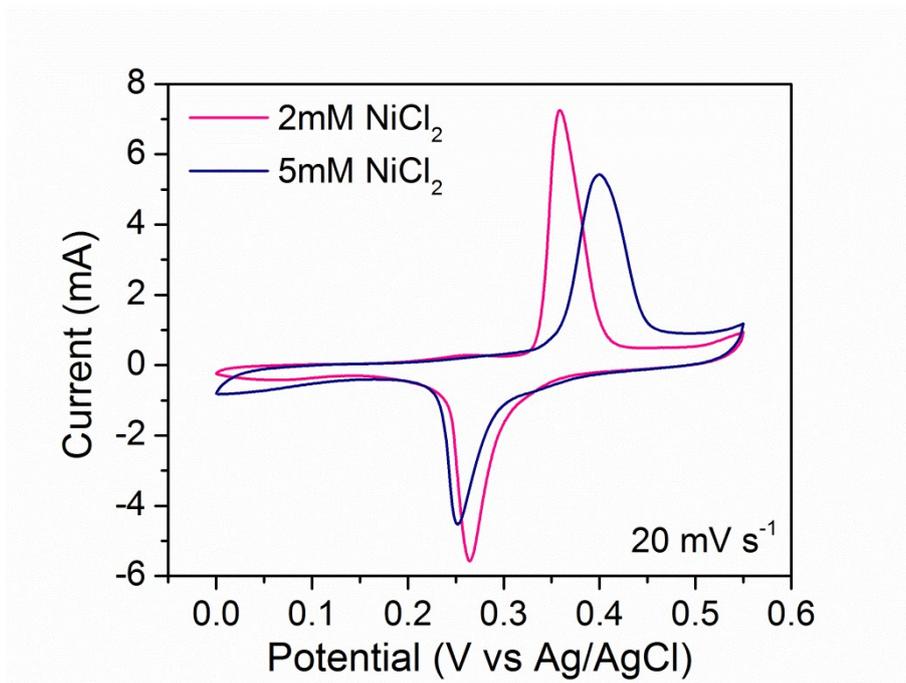


Figure S7. Comparison of CV curves for NP Au/VA Ni(OH)₂ with different loading of Ni(OH)₂, which is controlled by using different concentration of precursor NiCl₂. The scan rate is 20 mV s⁻¹.

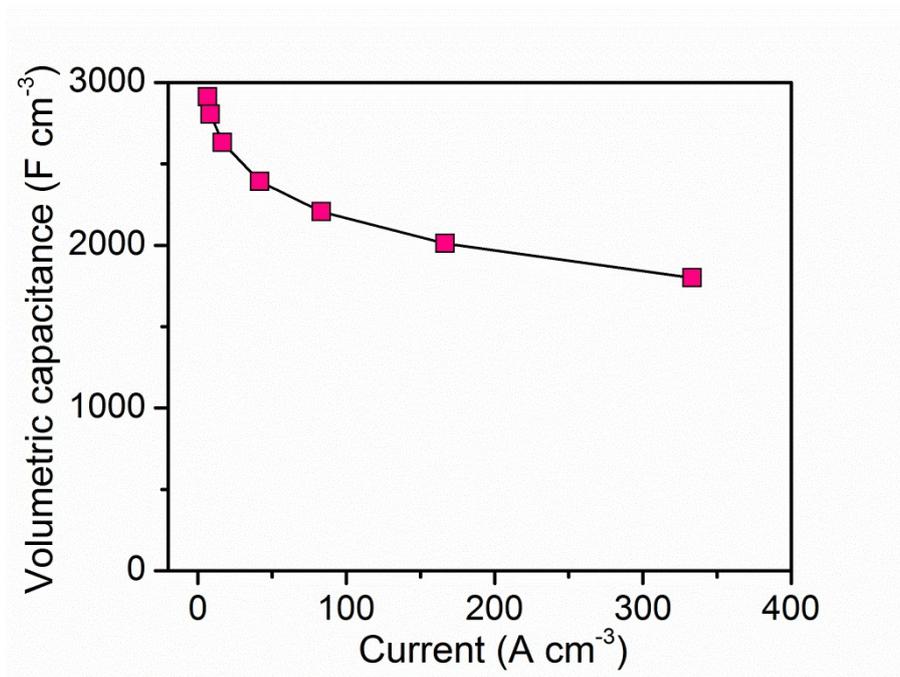


Figure S8. Volumetric capacitance of NP Au/VA Ni(OH)₂ electrode as a function of volumetric current density.

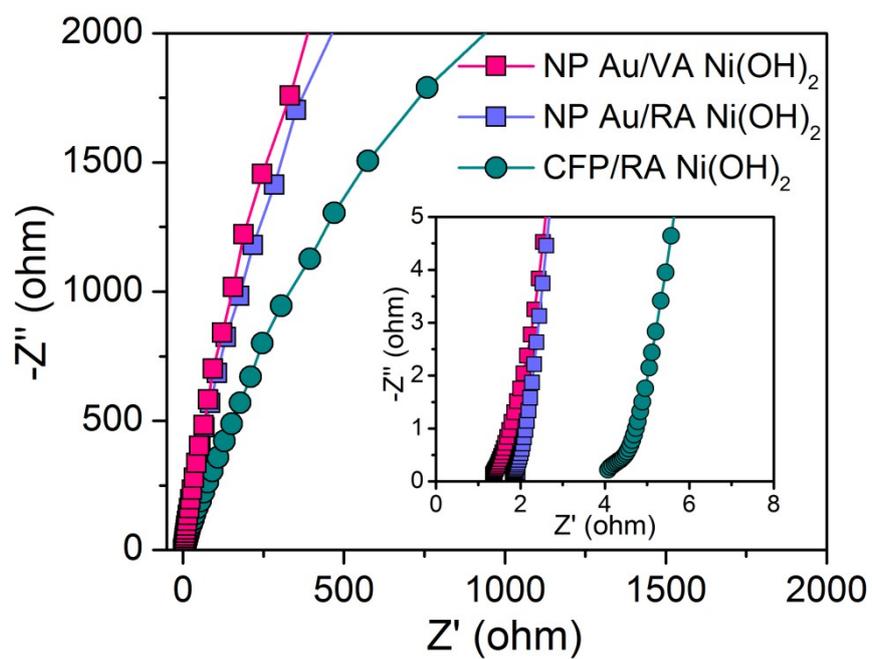


Figure S9. Complex plane plot of the impedances of NP Au/VA Ni(OH)_2 , NP Au/RA Ni(OH)_2 and CFP/VA Ni(OH)_2 electrodes, with a magnification for the high frequency region in the inset.

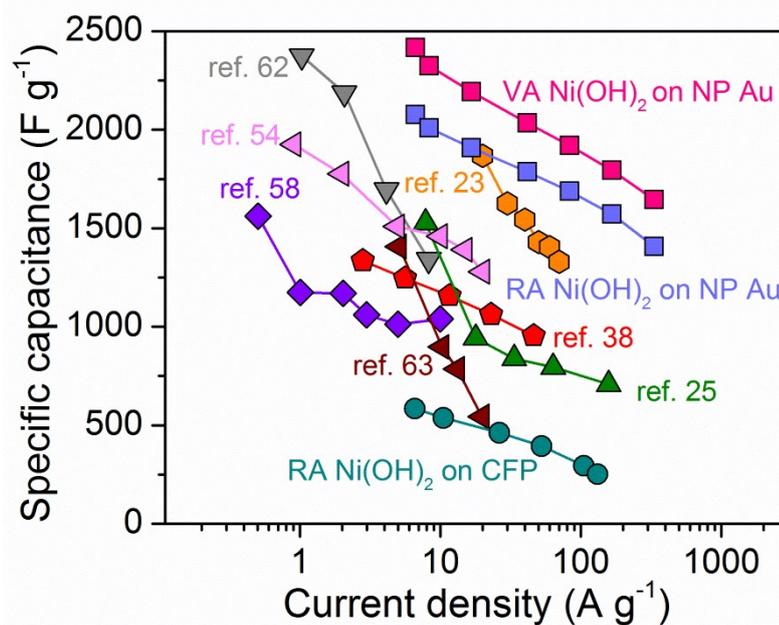


Figure S10. Specific capacitance of constituent VA Ni(OH)₂ on NP Au, in comparison with RA Ni(OH)₂ on NP Au, RA Ni(OH)₂ on CFP and other previously reported Ni(OH)₂-based electrodes, such as graphite/amorphous Ni(OH)₂,²³ Ni foil/3D Ni(OH)₂,²⁵ graphene/Ni(OH)₂,³⁸ Au nanoparticles-deposited Ni(OH)₂,⁵⁴ 3D graphite foam/Ni(OH)₂,⁵⁸ Ni foam/CoO/Ni(OH)₂,⁶² and 3D graphene/Ni₃S₂/Ni(OH)₂ electrodes.⁶³

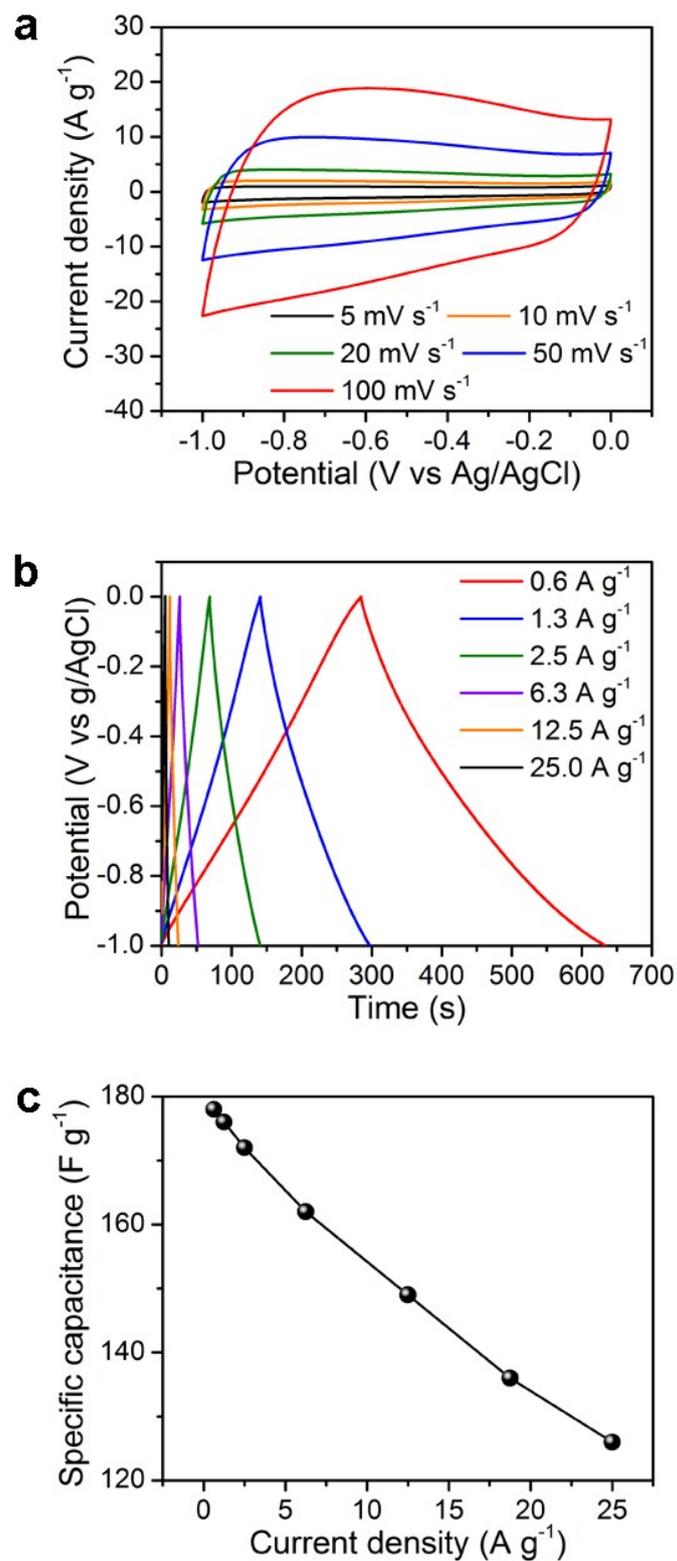


Figure S11. Electrochemical performance of AC electrode. **(a)** CV curves, **(b)** charge/discharge profiles and **(c)** specific capacitance of the AC electrode derived from discharge curves.

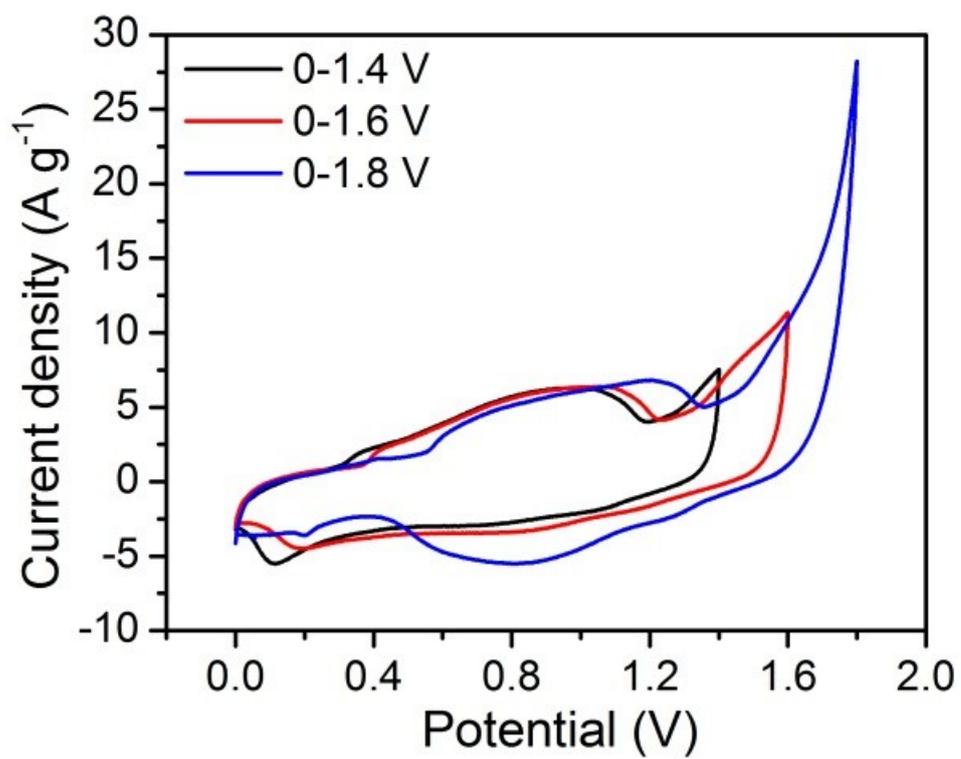


Figure S12. CV curves of ASC device at various potential windows at 20 mV s⁻¹.

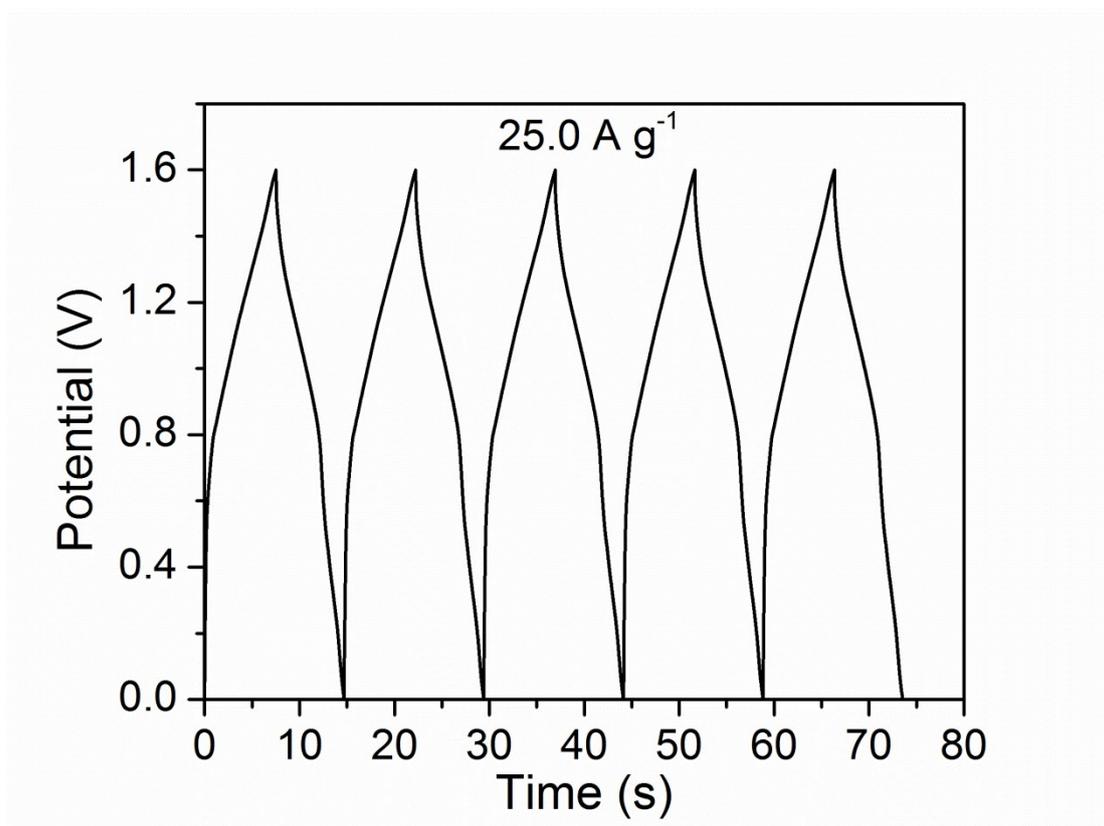


Figure S13. Charge-discharge curves of ASC device at a current density of 25.0 A g^{-1} .

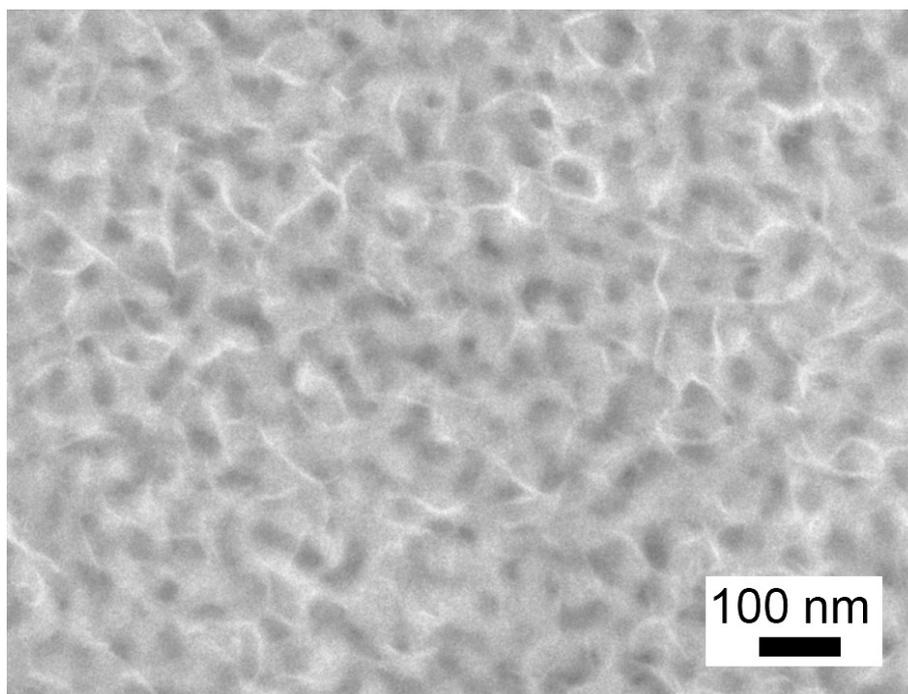


Figure S14. SEM image of NP Au/VA Ni(OH)₂ after the stability test of 10000 cycles.